

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

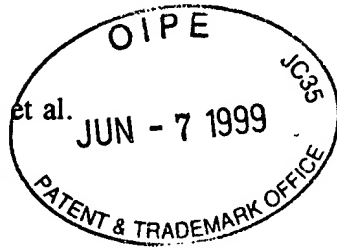
In re application of

Hiroshi TAKANASHI et al.

Serial No. 09/262,077

Filed March 4, 1999

NEGATIVE-WORKING PHOTSENSITIVE :
RESIN COMPOSITION AND
PHOTSENSITIVE RESIN PLATE USING
THE SAME



Group Art Unit 1753

Examiner

Handwritten: #3
P.W.
6-22-99

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GROUP 1700

INFORMATION DISCLOSURE STATEMENT

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

Pursuant to the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, Applicants request consideration of (X) the references listed on the attached Form PTO-1449 and/or () the additional information identified below in paragraph 4. A legible copy of each reference listed on the Form PTO-1449 is enclosed, except a copy is not provided for each reference previously cited by or submitted to the Patent Office in prior parent application Serial No. _____.

1. This Information Disclosure Statement is submitted:

- a. ☐ within 3 months of the filing date of the above-identified application, or
☐ within 3 months of entry into National stage prosecution of an International application, or ☒ before the mailing date of the first Office Action on the merits, and thus:

☒ no certification and/or fee is required.
- b. ☐ after the events of above paragraph 1a and prior to the mailing date of a final Office Action or Notice of Allowance, and thus:

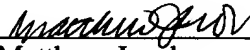
☐ the certification of paragraph 2 below is provided,
or
☐ a fee of \$240.00 is enclosed.

() reference is made to the concise explanation set forth below:

6. () Applicant also offers the following comments for the Examiner's consideration:
7. () Also enclosed is a copy of the European Search Report citing these references.

Respectfully submitted,

Hiroshi TAKANASHI et al.

By 
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June 7, 1999